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FILING DATE.**

APPLICATION NUMBER: 60/390,839

FILING DATE: June 21, 2002

RELATED PCT APPLICATION NUMBER: PCT/US03/19580

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PROVISIONAL APPLICATION FOR PATENT COVER SHEET

This is a request for filing a PROVISIONAL APPLICATION FOR PATENT under 37 CFR 1.53(c)

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 BOX PROVISIONAL APPLICATION
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11017 U.S. PTO
 60/390839
 06/21/02

Transmitted herewith for filing is the Provisional Patent application of:

Given Name (first and middle [if any])	Family Name or Surname	Residence
1. Steven D.	Cech	670 Rock Creek Drive Aurora, Ohio 44202
2. Don W.	Cochran	13665 Braeburn Lane Novelty, Ohio 44072
3. Thomas H.	Palombo	1291 N. Revere Road Akron, Ohio 44333
4. Michael L.	Yoder	385 Broad Street Wadsworth, Ohio 44281
5. Jesse	Booher	4412 LaFrance Newton Falls, Ohio 44444
6. Terry L.	Graves	484 Allen Drive Wadsworth, Ohio 44281

- All inventors are citizens of the U.S.A.

Title of the invention:

**PATTERNED ILLUMINATION METHOD AND APPARATUS
 FOR MACHINE VISION SYSTEMS**

Enclosed application parts:

- ☒ 11 Pages of Specification
- ☒ 6 Sheets of Drawings
- ☒ 1 Page of Abstract
- ☐ Application Data Sheet
- ☐ CD(s)
- ☐ Other (specify) _____

Method of Payment of Filing Fees for this Provisional Application for Patent:

- ☒ Applicant claims small entity status. See 37 CFR 1.27.
- ☒ A check is enclosed to cover the filing fees.
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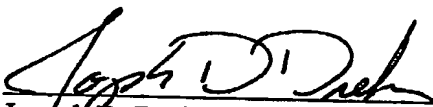
Direct all telephone calls to:

Richard J. Minnich, Esq.
telephone: 216/861-5582
facsimile: 216/241-1666
E-mail: rminnich@faysharpe.com

Direct all correspondence to:

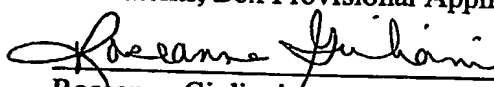
Richard J. Minnich, Esq.
FAY, SHARPE, FAGAN,
MINNICH & McKEE, LLP
1100 Superior Avenue,
Seventh Floor
Cleveland, Ohio 44114-2518

Date: June 21, 2002


Joseph D. Dreher
Reg. No. 37,123
FAY, SHARPE, FAGAN,
MINNICH & McKEE, LLP
1100 Superior Avenue
Seventh Floor
Cleveland, Ohio 44114-2518
216/861-5582

Express Mail Label No.: EV 020235773 US
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Roseanne Giuliani

Patterned Illumination Method and Apparatus for Machine Vision Systems

Background of the Invention

[0001] This application relates to an apparatus and method for providing patterned illumination fields for use within process control and article inspection applications. More specifically, it pertains to the use of patterned illuminators to enable visual surface inspection of polished objects such as ball bearings. While the invention is particularly directed to the art of high-speed automated process control and article inspection applications, and will be thus described with particular reference thereto, it will be appreciated that the invention may have usefulness in other fields and applications. For example, the invention may be used as an illumination source for manual or operator-initiated inspection of parts.

[0002] By way of background, the use of engineered lighting systems within automated inspection systems is well known in the art. For example, U.S. Patent Number 4,882,498 entitled "Pulsed-Array Video Inspection Lighting System" describes a method and apparatus related to engineered lighting system for machine vision applications. Amongst other things this invention introduces the concepts of spatially distributing and high-current pulsing solid-state lighting elements within the engineered illumination system. Both of these innovations worked to allow autonomous machine vision to be advantageously applied to an expanding class of application areas. Similarly, U.S. Patent Number 6,238,060 entitled "Machine Vision Ring-Reflector Illumination System and Method" describes an innovation related to the implementation of a ringlight-based illumination system. One embodiment of this referenced patent is an illumination system capable of generating configurable dark field illumination. There is a volume of prior art descriptions which indicates the appropriateness and usefulness of dark field illumination to highlight surface anomalies (such as scratches and pits) occurring on generally flat polished surfaces. While introducing improvements in

the areas of ease of deployment and dark field configurability, the referenced invention is limited in generally the same fashion as all prior art ringlight implementations in regards to its ability to provide complete and uniform illumination fields for the case of contoured, 3-dimensional, specular surfaces. On these classes of parts, the directional lighting associated with ringlight illumination causes uneven returns from the part under inspection. In addition to getting scatter-induced reflections at defect locations such as scratches and pits (which are preferred), intense image artifacts are also generated at all locations wherein the local surface orientation (due to normal part contours) allow light emitted by the ringlight source to be specularly-reflected into the receiver aperture of an associated inspection system. As these image artifacts or hot-spots are typically intense enough so as to drive any receiving entity into high scale saturation, inspection (automated or otherwise) is not generally possible in these areas. In addition, due to general shadowing effects caused by the 3-dimensional nature of the part under inspection, it is possible for areas of the part to receive little to no incident illumination if ringlight or other dark field illumination technique is exclusively used to image these classes of parts.

[0003] Many of the objects typically inspected using automated machine vision systems happen to be specular and 3-dimensional in nature. Included in this list are metal cans and closures, ball bearings, electrical contacts, and populated electrical assemblies. To adequately inspect these and other complex parts, hundreds of additional prior art improvements to the illumination portions of these inspection systems have been devised and implemented. To address the specific inspection needs associated with highly specular, 3-dimensional parts, various forms of an illumination system typically described as a continuous, diffuse illuminator have been designed, constructed, and applied within inspection systems. They are well known in the art. Such a continuous diffuse system was described in the 1985 textbook, Automated Visual Inspection, by Batchelor, Hill, and

Hodgson. These lighting systems differ from directional ring light sources in that they are designed to generate lighting fields that illuminate parts under inspection from essentially all directions. These illuminators often take the geometric form of a hemisphere surrounding the part under inspection. Constructed in this manner, continuous, diffuse lighting systems allow uniform gray scale images of highly specular, 3-dimensional parts to be acquired. Images that are generally uniform in gray scale intensity advantageously enable automated, high-speed analysis. When illuminated in this fashion, specular, 3-dimensional parts can be adequately inspected for a number of classes of defects including absorptive-type defects (such as contamination) as well as gross part deformations.

[0004] While it is sometimes possible to detect surface scratches or pits using continuous diffuse lighting systems, the performance of these systems on these classes of defects is not optimal. The angularly-uniform and complete nature of the impinging light stimulus creates a condition wherein scatter effects caused by surface scratches and the like are effectively blanketed over and masked by natural specular reflections occurring on the surrounding non-defective surface. To best highlight these types of defects on highly specular parts, it is still best to use directional lighting.

[0005] As an illustration of one specific example of a continuous, diffuse lighting system, U.S. Patent Number 6,341,878 entitled "Method and Apparatus for Providing Uniform Diffuse Illumination to a Surface" describes an improvement in the state of the art of uniform diffuse illumination which places the emitting light source below the part under inspection. In doing so, the ability of the lighting system to generate low angle illumination is improved. This invention also references a hemispherical diffuser located above the part under inspection and the deployment of crossed linear polarizers (one over the emitting light elements and one at the receiver aperture).

[0006] The present invention overcomes difficulties noted above and others. It also provides distinct advantages over heretofore known systems.

Summary of the Invention

[0007] The present invention is directed to an apparatus and method of providing patterned lighting fields to support the visual inspection of highly specular, 3-dimensional parts. The disclosed illuminator consists of a source of patterned, diffuse light that is situated largely above an object being inspected. In the preferred embodiment, this upper light source is implemented as a hemispherical reflector or diffuser wherein the patterned zones of illumination are laid out in annular rings about a central view port. Located below the part being inspected is an additional diffuse, patterned light source. This light source is used to generate patterned low angle illumination that is required for some part geometries. In the preferred embodiment, the lower illuminator is implemented as a 2-dimensional panel source wherein the patterned zones are laid out in annular zones about a central axis.

[0008] In one aspect of the present invention, a directional illuminator is provided that is constructed in a fashion wherein the image hot-spot artifacts created by specular reflections off of areas of non-defective part surfaces are of the variety which enable autonomous processing and detection operations to occur.

[0009] In another aspect of the present invention, an illuminator is provided that is constructed to provide advantageous directional or dark field illumination over controlled areas across the entire surface of a specular, 3-dimensional part.

[00010] In another aspect of the present invention, a patterned illuminator is provided which produces a controlled hot-spot pattern within the acquired image field that both allows existing defect detection algorithms to execute while, in addition, provides directional or dark field illumination to selected and controlled areas across the entire part surface. This

combination of illuminator attributes enables the high-performance, automated inspection of highly specular, 3-dimensional parts for the presence of critical surface defects such scratches or pits.

[00011] An advantage of the present invention is that it provides directional lighting across the full surface of highly specular, 3-dimensional parts.

[00012] Another advantage of the present invention is that it produces controlled hot-spot image artifacts that allow high-speed automated inspections to take place.

[00013] Yet another advantage of the present invention is that it allows highly specular, 3-dimensional parts to be inspected for the presence of critical surface flaws such as scratches and pits.

[00014] Further scope of the applicability of the present invention will become apparent from the detailed descriptions provided below. It should be understood, however, that the detailed descriptions and specific examples, while indicating preferred embodiments of the invention, are given by way of illustration only, since various changes and modifications within the spirit and scope of the invention will become apparent to those skilled in the art.

Detailed Description of the Drawings

[00015] The present invention exists in the construction, arrangement, and combination of the various parts of the device, and steps of the method, whereby the objects contemplated are attained as hereinafter more fully set forth and illustrated in the accompanying drawings which:

[00016] Figure 1 is a cross-sectional schematic diagram of a prior art ringlight source capable of generating dark field illumination over only a portion of a hemispherically-shaped part;

[00017] Figure 2 is a close-up schematic representation of the interaction of light rays at the surface of specular, 3-dimensional surface;

[00018] Figure 3 is a block diagram illustrating an illuminator according to the present invention;

[00019] Figure 4 is a flow chart illustrating the preferred lighting method according to the present invention;

[00020] Figure 5 is a flow chart illustrating an alternate lighting method according to the present invention; and

[00021] Figure 6 is an illustration of an alternative embodiment of the present invention.

Detailed Description of the Invention

[00022] Referring now to the drawings wherein the showings are for the purposes of illustrating preferred embodiments of the invention only and not for purposes of limiting the same, Figure 1 provides a cross-sectional schematic view of a prior art ringlight illuminator. As shown, the part under inspection 30 is illustrated as a domed object approaching the general shape of a hemisphere. Note that this choice of part shape is done for the purposes of illustration and should not be interpreted so as to limit in any manner the applicability of this invention to other areas of inspection.

[00023] In this prior art implementation, light-emitting diodes (LEDs) 20 are deployed in an annular fashion and are used to generate a line source of generally narrow spatial extent that diverges from its emission point and is directed onto the surface 55 of a centrally located part under inspection 30. In this Figure, a single optical ray 40, emitted by the LED source 20, is ejected at an angle wherein a direct specular reflection off of the normal surface contour results in the ray being directly received at a receiver aperture 10. A bright image

artifact or hot-spot will be formed in this position in an annular pattern of constant radius about the part/receiver aperture axis 70. The perceived width of this specular image artifact will be dependent on the spatial extent of the LED source 20 and the physical extent of the receiver aperture 10. Also indicated on this Figure are tow areas on the surface 55 of the part of local surface perturbation or defect 50. In these areas, due to the presence of scratches, pits, dents, etc., the part surface 55 deviates from its normal figure. These deviations, depending on their depth and orientation, can scatter incident photons that would not otherwise be detected into the active region of the receiver aperture 10.

[00024] This simplified presentation outlines the process wherein directional or dark field lighting can be enacted to stimulate the detection of scratches or the like on the surface of specular surfaces. The two rays identified as 60 are rays that have undergone this type of advantageous scattering action.

[00025] Figure 2 depicts a close-up schematic view of the interaction of incident dark field illumination with a part under inspection 30. In Figure 2, the specular ray 40 is identified as it has been discussed above. Surface defects 51, 52 and 53 are indicated on the part surface 55. As it is indicated in this Figure, the relatively shallow indentation associated with defect 51 allows dark field illumination as described in Figure 1 to reflect in a direction which would allow entrance into the receiver aperture 10. Ray 61 represents the scatter-induced reflection off of the indented surface of defect 51. A surface perturbation drawn to the same general depth as defect 51 but placed in a different location on the part 30 (indicated as defect 52) results in a completely different degree of detectability using this same ringlight source. Ray 62 represents the scatter-induced ray generated by defect 52. Ray 62 does not reach the receiver aperture 10 as defined in Figure 1 and, therefore, would go undetected. By drawing the depth of the surface defect down as is indicated by defect 53, it is

possible to generate a ray 63 that is scattered by a simple ringlight source in a direction advantageous to its detection.

[00026] What can be concluded from this simplified analysis of the physics of reflection at the surface of a specular surface is that a defect's degree of perturbation as well as its proximity to the location of the dark field specular artifact both have an impact on its detectability. Defect 51 is relatively close to the specular ray 40 and, therefore, it does not take much surface perturbation at this location to enact advantageous scattering. In contrast, the location of defects 52 and 53 are relatively removed from the specular ray 40 and, consequently, only the gross defect 53 is detectable.

[00027] With this as background, Figure 3 is now presented and represents the preferred embodiment of the present invention. In the preferred embodiment, the part under inspection 30 is fixtured within the illuminator 65 via a support/transport mechanism 100. Located above the part under inspection 30 is a patterned diffuse light source 90, preferably constructed in the form of a hemisphere. In the preferred embodiment, the support transport mechanism 100 is constructed in a fashion that allows illumination to be incident on the part 30 from below. In this manner, an additional patterned diffuse light source 110 can be deployed to provide advantageous illumination from below the part 30. The patterned light sources 90 and 110 are preferably constructed to provide spatially alternating areas of intense uniform light 91 and dark areas or lighting voids 92. This alternating pattern of intense light 91 and lighting voids 92 creates a pattern, within the reflected image field, of structured specular regions adjacent to regions of advantageous dark field illumination as it has been described in reference to Figures 1 and 2. In these dark field regions, the detection of surface defects such as scratches or pits will be optimized. Within the adjacent specular regions, defect detection will still be as good or better than that attainable using continuous diffuse lighting techniques. If preferred dark field illumination is required over all surface areas of

the part, a second illuminator configured with the alternate illumination pattern can be deployed in sequence with the original illuminator 65. One skilled in the art of machine vision illumination will understand that by making adjustments to the spacing (size of dark versus light areas) that signal-to-noise ratio can be further optimized for various types of surface defects.

[00028] In the preferred embodiment, the intense light 91 and lighting void 92 regions are defined as alternating annular regions. A patterned illuminator constructed using concentric regions results in a part image containing alternating dark and bright concentric regions. Many parts that are inspected using automated machine vision systems are generally round in nature. Inspection algorithms that are designed to operate within specific annular regions of the imaged part are well known in the art. For this reason, a patterned illuminator that creates annular zones of inspection is preferred. However, the spirit of the inventions includes the implementation of a patterned illuminator of arbitrary pattern.

[00029] Additionally, within the scope of the present invention, the alternating illumination pattern can, in an alternate construction, be fabricated as regions of alternating spectral properties. With the deployment of proper spectral filtering within the receiving aperture 10 of the illuminator 65, advantageous dark field illumination can still be enacted over the part surface 55. For example, by utilizing two different wavelengths of light, it is possible to use two different cameras – each filtered to only see its respective wavelengths and thus have continuous coverage by selected treatment of the respective camera image information.

[00030] Integrated as part of the hemispherical upper light source 90 is a view port 120. The view port 120 allows a receiving aperture 10 to be positioned to receive reflected or scattered light coming off the part under inspection 30. Provision is also made within the preferred embodiment for the placement of a beamsplitter component 75 between the

hemispherical light source 90 and receiving aperture 10. The beamsplitter 75 is used to re-direct light generated by center light source 80 into the location of the view port 120. This completes the continuous nature of the incident lighting fields.

[00031] The patterned illuminators 90 and 110 are preferably fabricated as translucent diffusers backlit by lighting elements. The spatial illumination pattern key to the present illumination is preferentially created by placing a masking element on the surface or, alternately, within the volume of alternating and adjacent regions of the diffuser. In the case of the upper hemispherical light source, an alternate means of creating the patterned light source is to use a patterned reflector dome designed to reflect (in alternating high-reflectivity/low-reflectivity annular regions), incident light emitted by the lower backlight source 110. Implemented in this fashion, a reflector dome as defined appears, to the part under inspection 30, as if it were a primary source of the required patterned illumination.

[00032] An alternative embodiment would be as shown in Figure 6 wherein a series of ring lights 300, and ring lights 310, would be configured such that there is a dark space (no light produced) between each of the ring lights. They would form a hemisphere which would produce light in alternate annular rings. Also shown are the aperture 10 and object 30 having a surface 55.

[00033] Referring now to Figure 4, one preferred illumination method 200 reflecting the basic steps of operation is shown. Initially, the part under inspection 30 is positioned in a preferred location within the illuminator 65 (step 205). Light energy from the illuminator 65 is directed onto the surface of the part 55 (step 210). Finally, light reflected or scattered off the part (such reflection or scattering containing information related to the part's quality) is made available for detection at the receiver aperture 10 (step 215).

[00034] Alternately, Figure 5 describes an extension of the basic method wherein a second illuminator is used in sequential fashion with the first illuminator 65 (method 202). In

method 202, the second or alternate illuminator is configured having a complementary intense light 91/lighting void 92 pattern as compared to the original patterned illuminator 65. As defined, the additional steps outlined as 220, 225, and 230, performed after steps 205, 210, and 215, effect complete coverage of the parts surface 50 using preferential dark field illumination.

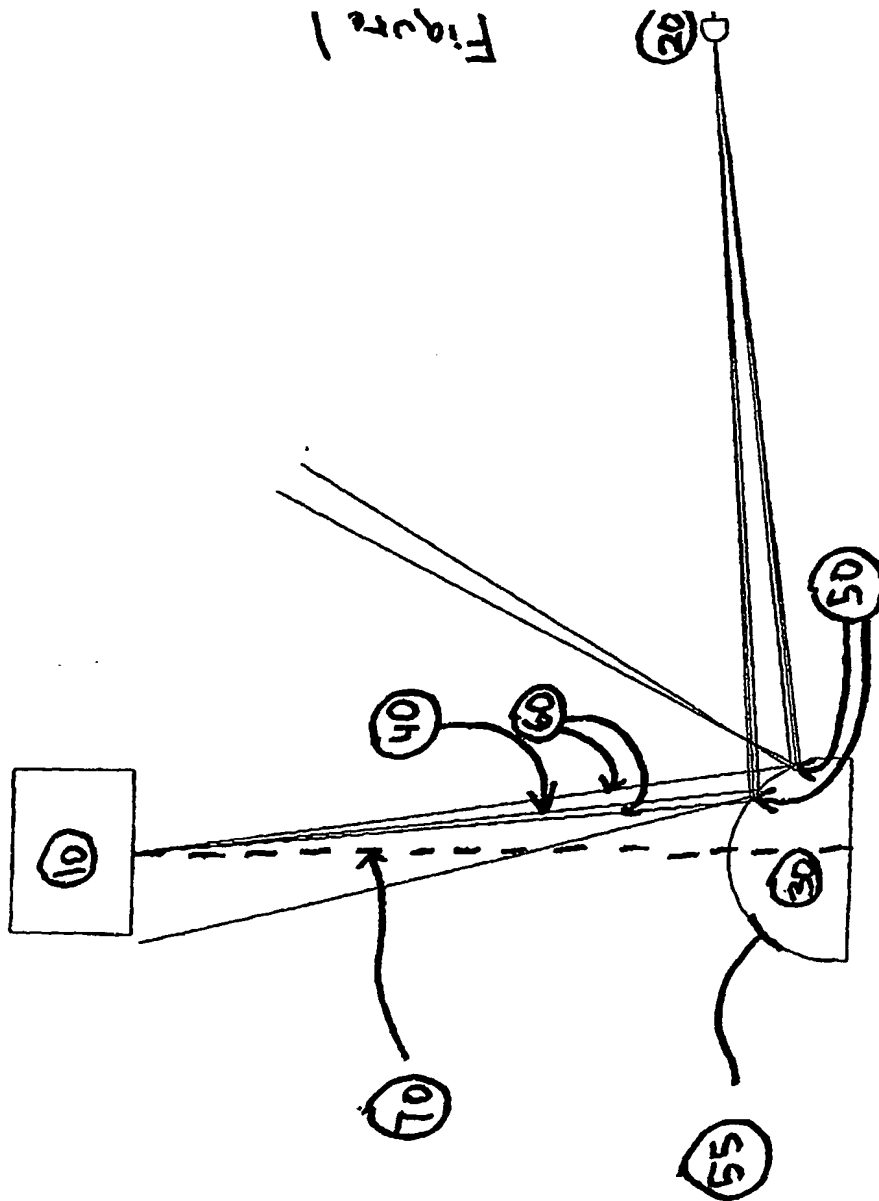
[00035] The above description merely provides a disclosure of particular embodiments of the invention and is not intended for the purposes of limiting the same thereto. As such, the invention is not limited to only the above-described embodiments. Rather, it is recognized that one skilled in the art could conceive alternative embodiments that fall within the scope of the invention.

Patterned Illumination Method and Apparatus for Machine Vision Systems

Abstract

[00036] This application relates to an apparatus and method for providing patterned illumination fields for use within process control and article inspection applications. More specifically, it pertains to the use of patterned illuminators to enable visual surface inspection of polished objects such as ball bearings. The use of patterned illuminators properly disposed in relation to a polished part under inspection allows small surface imperfections such as scratches and pits to become visible against the normal surface background. The use of carefully engineered illuminators facilitates advantageous defect-site scattering from generally dark field sources. The patterned nature of the illuminators defined by this invention allows the complete surface of three-dimensional parts to be effectively highlighted using dark field illumination fields.

Figure 1



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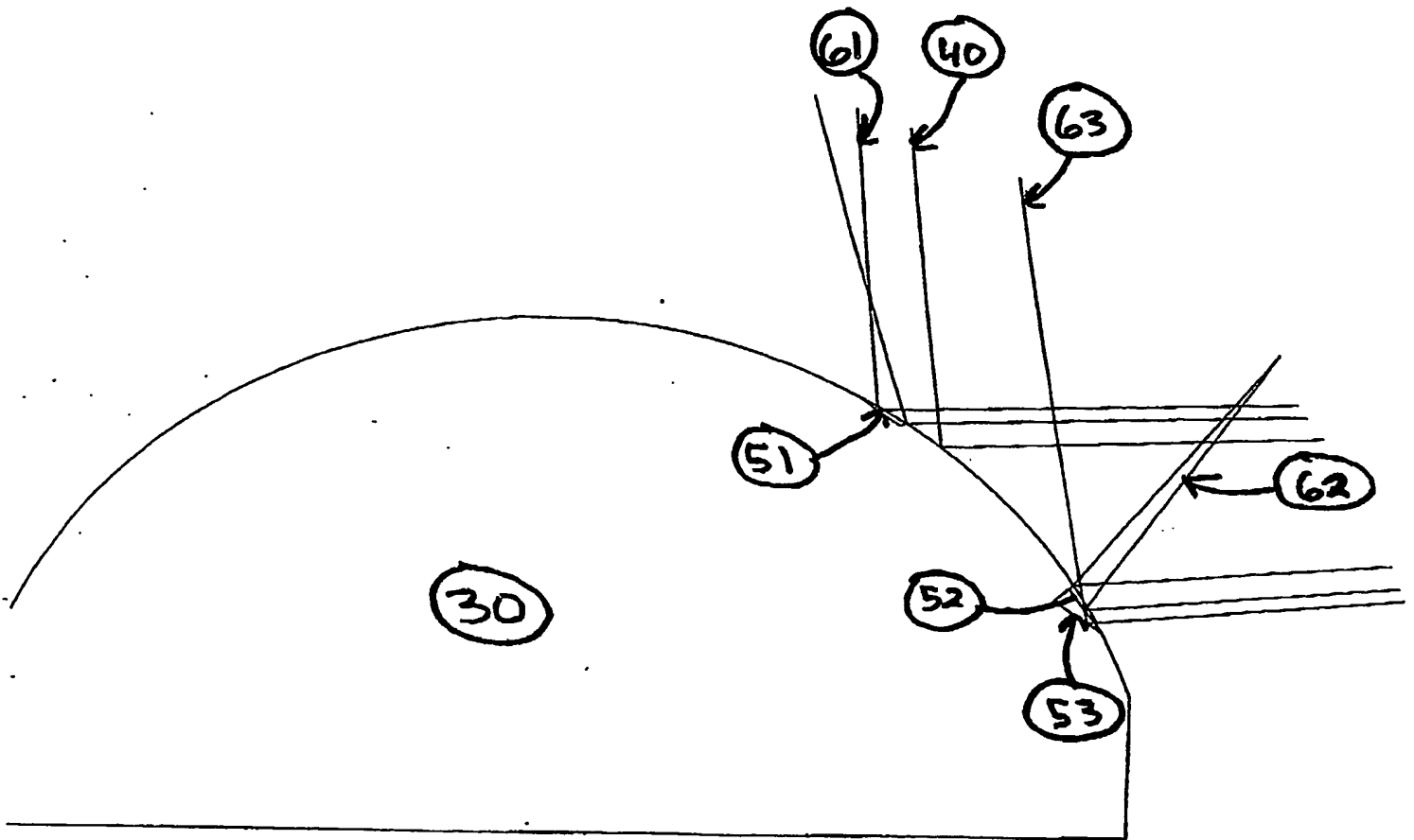


FIGURE 2

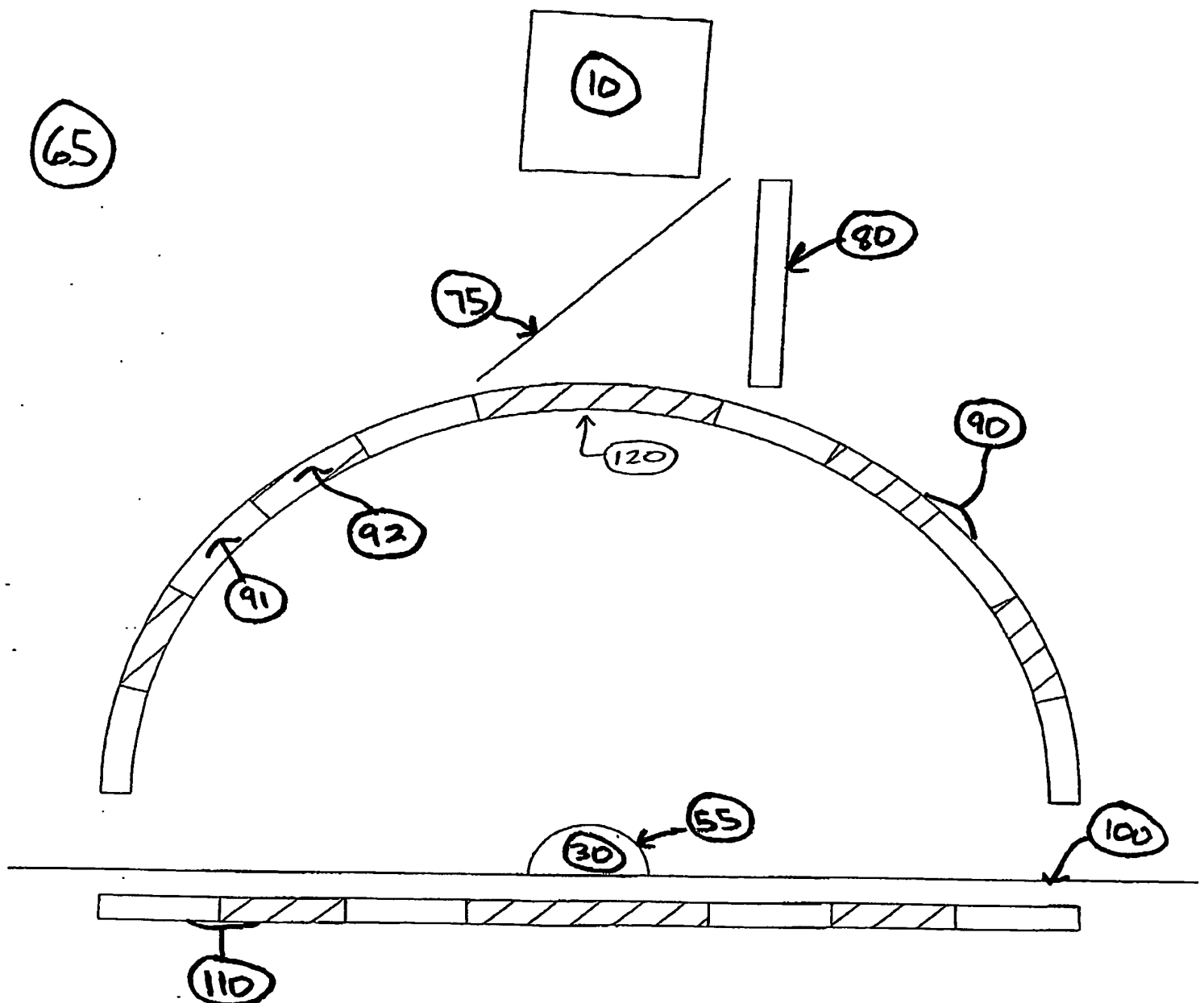


Figure 3

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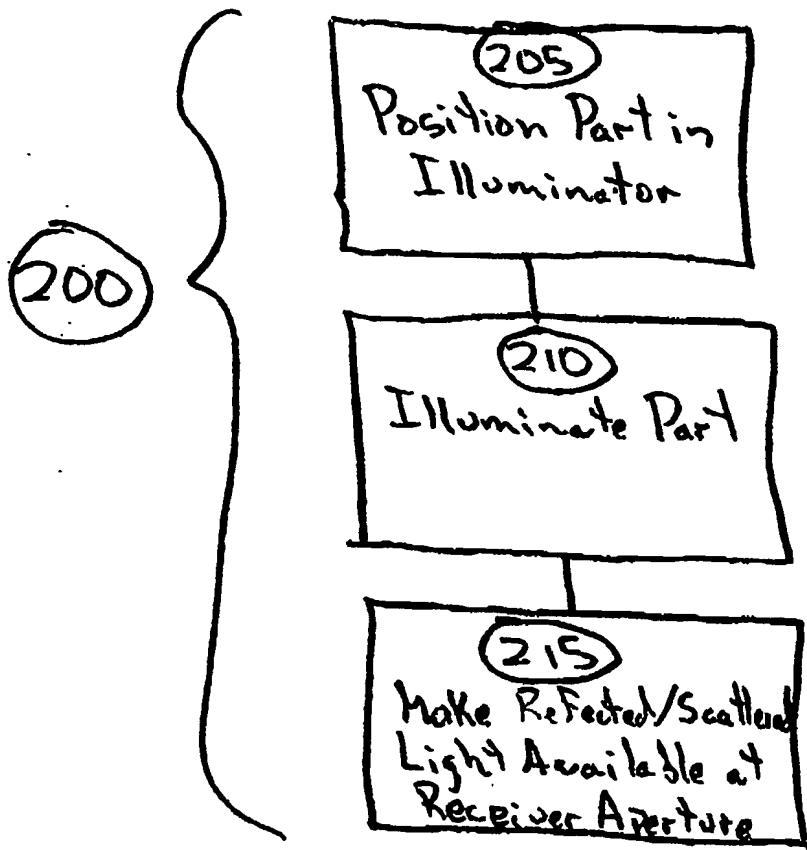
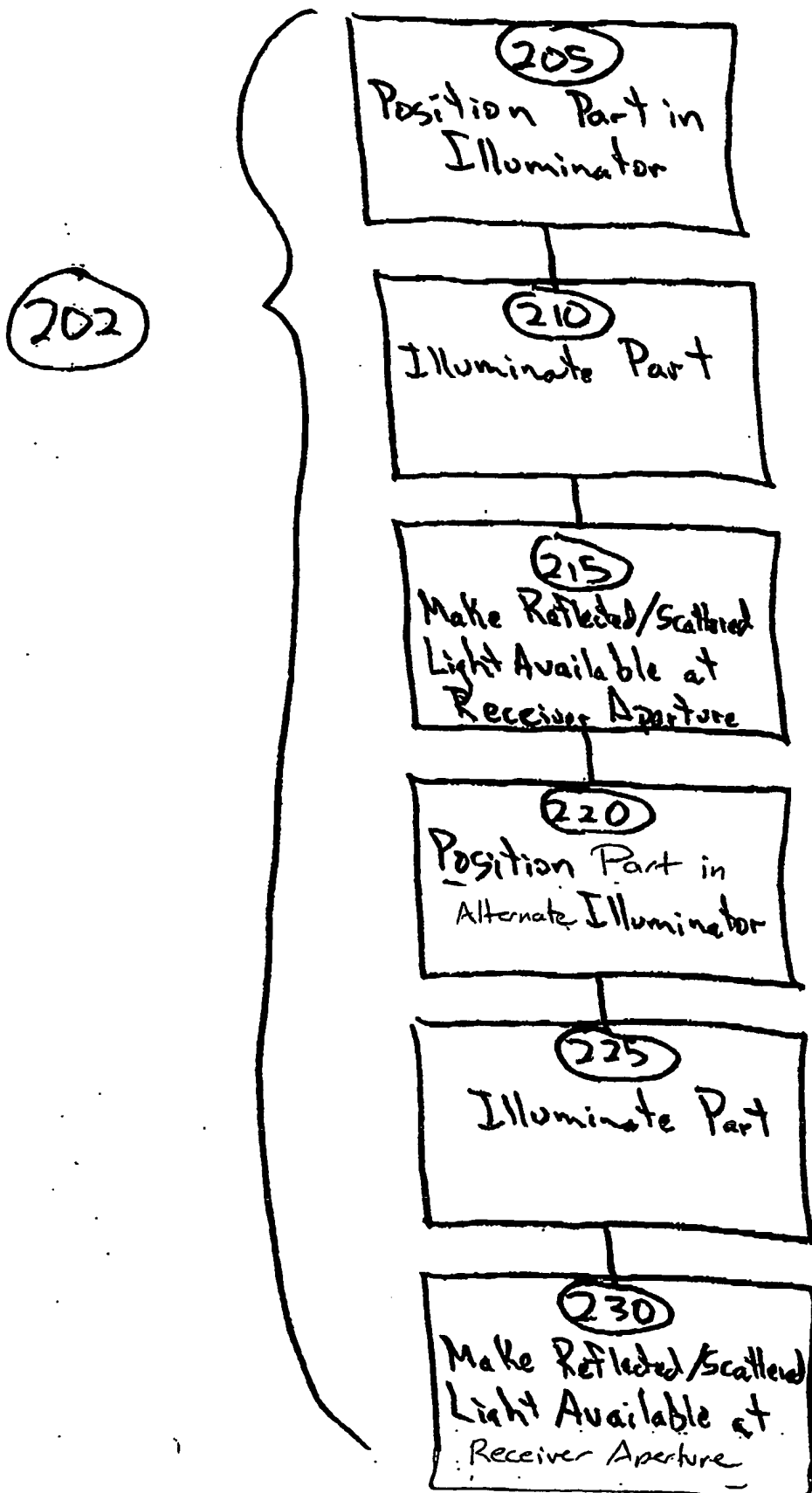


Figure 4

FIGURE
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